Accepted Manuscript

 N_2O+CO reaction over single Ga or Ge atom embedded graphene: A DFT study

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PII:S0039-6028(17)30409-0DOI:10.1016/j.susc.2017.10.001Reference:SUSC 21103

To appear in: Surface Science

Received date:	3 June 2017
Revised date:	9 August 2017
Accepted date:	2 October 2017



Please cite this article as: Mehdi D. Esrafili , Esmail Vessally , N_2O+CO reaction over single Ga or Ge atom embedded graphene: A DFT study, *Surface Science* (2017), doi: 10.1016/j.susc.2017.10.001

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Highlights

- The $N_2O + CO$ reaction is studied on the single Ga or Ge atom embedded graphene.
- The catalytic activity of the Ge-embedded graphene for $N_2O + CO$ reaction is larger than that of Ga-embedded one.
- The disproportionation of N₂O molecule does not occur on these surfaces at normal temperature.

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